e that contains the of the entire stackup environmental, proces- ation effects. ovide excellent align- e data showing variation production lots.
ation effects. ovide excellent align- e data showing variation
ation effects. ovide excellent align- e data showing variation
e data showing variation
production lots.
limited or no registration ndent on system
aterial and (prior) pro- a lamination.
here one can first mea- e scale errors locked in d verify layer to layer rtunity to compensate o drill to maximize yield.
enefit – purely reactive
ms measurement of by skiving may eliminate on optimization.

TABLE 1. An intelligent approach to predictive registration improvement.

Subsequent processes are not discussed in this article